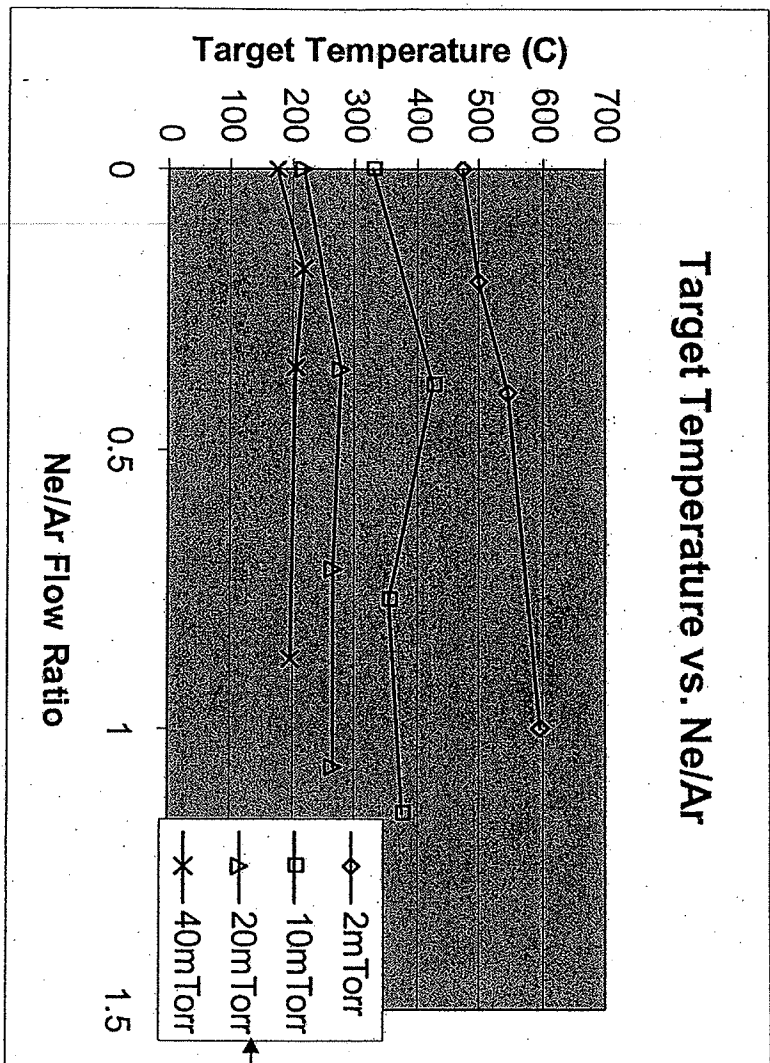


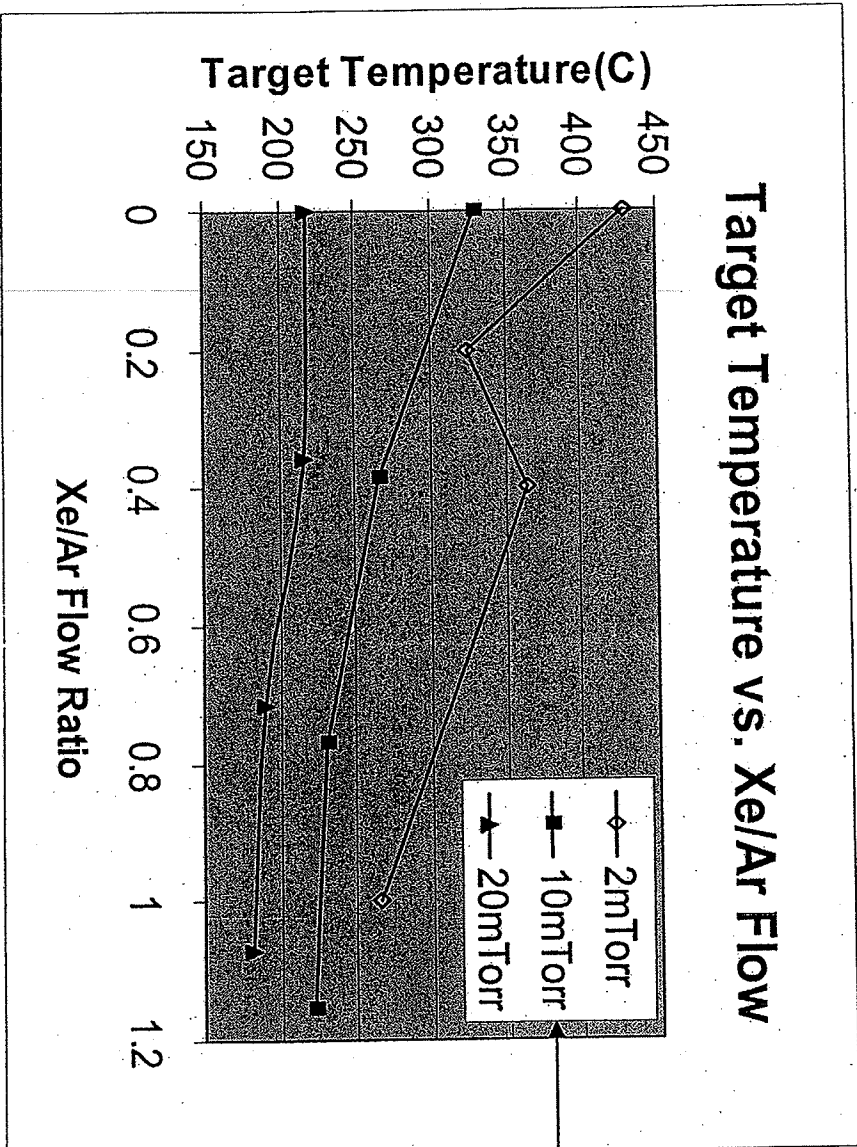
Ne Sputtering Target Temperature



*Pressure at 0
 Ne flow,
 pressure is
 higher with
 higher Ne
 flow

FIG. 7

Xe Sputtering Target Temperature



*Pressure at
0 Ne flow,
pressure is
higher with
higher Ne
flow

FIG. 8

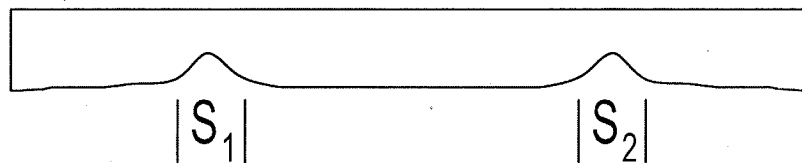


FIG. 12(a)

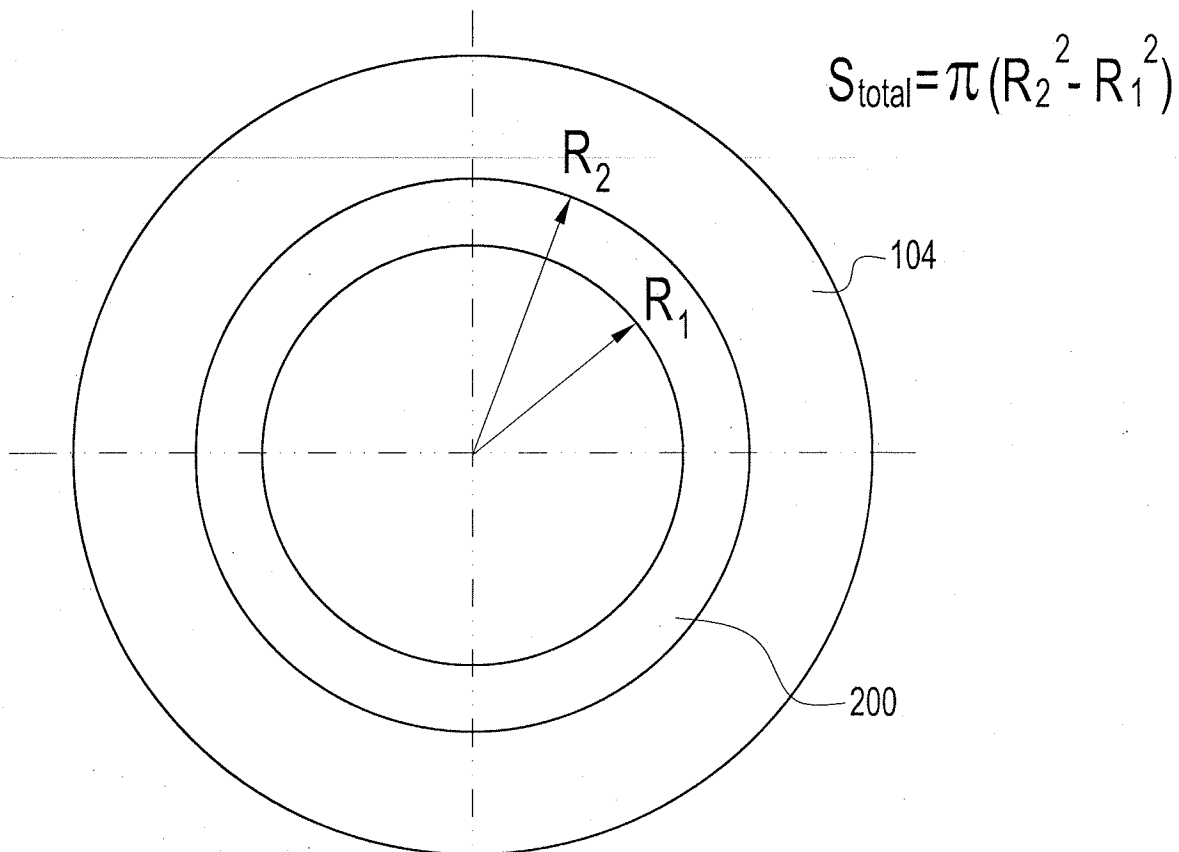


FIG. 12(b)

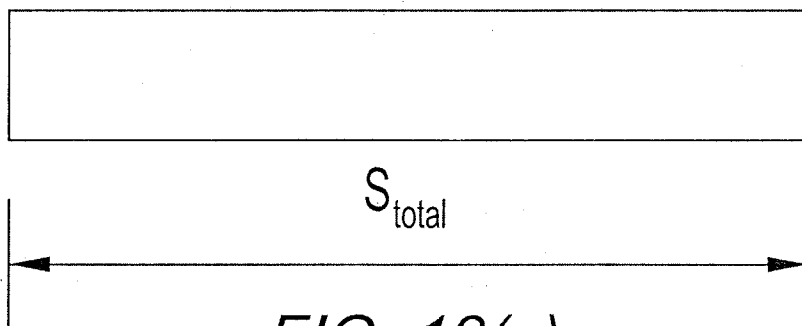


FIG. 12(c)

Ag₂Se on Ge₄Se₆

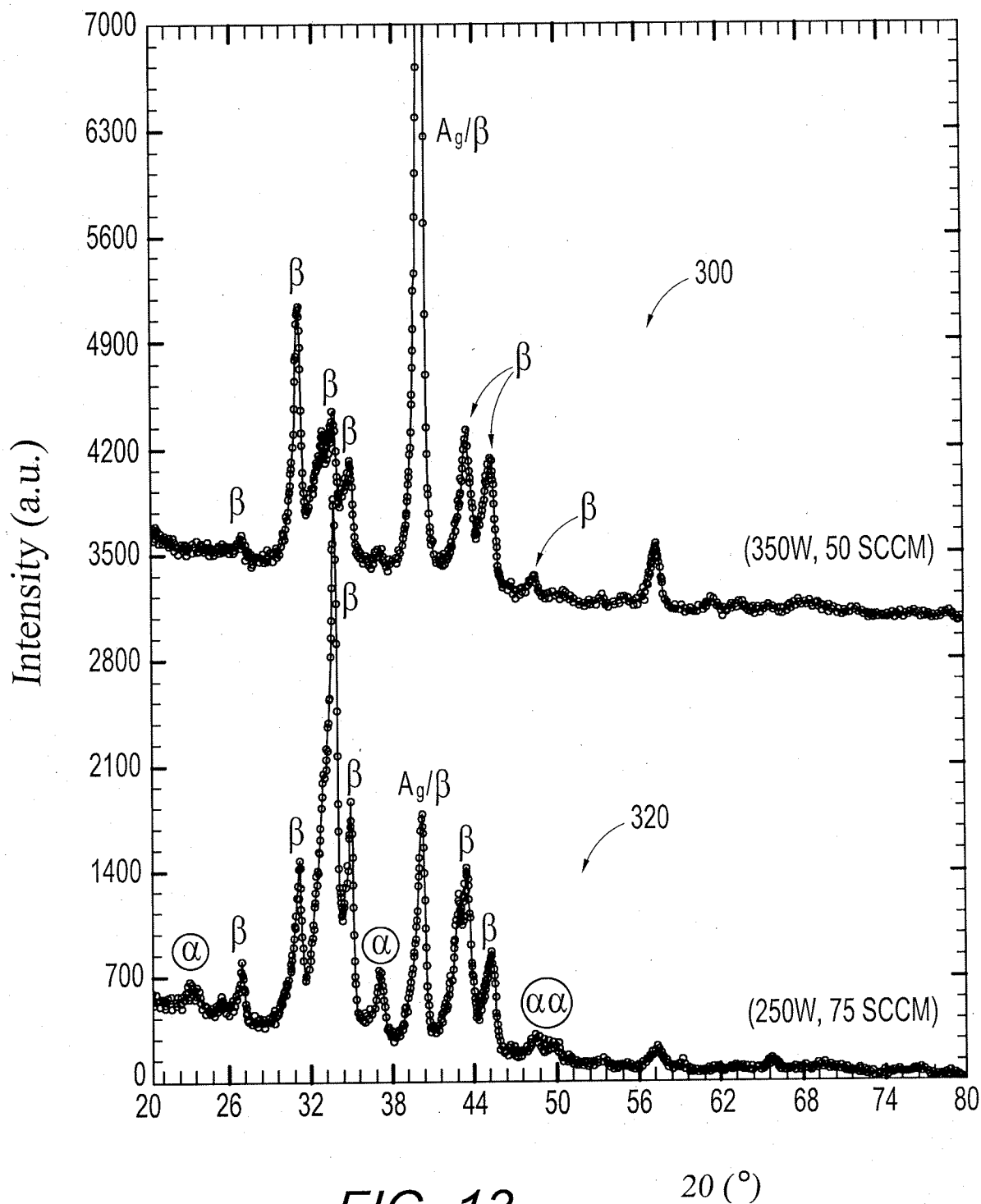


FIG. 13